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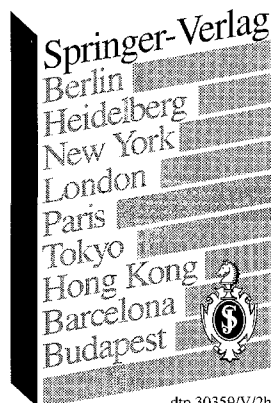
"This is one of those books that you cannot put down once you have started to look in it. It is a book that I wish had been available many years ago when, as a young newly appointed scientific manager, I was struggling with a mass of new ideas, rules, procedures, etc.: it would have saved me (and, no doubt, some of those I was managing) a great many headaches.

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The book is an absolute must for all engaged in the hi-tech industry, university and government laboratories, and engineers and scientists in, or moving to, administrative positions."

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